

**Amendments to the Specification:**

Please amend the specification by inserting the paragraph below, after the title on page 1.

**Cross-Reference to Related Application**

[0001.1] This application claims priority based on International Patent Application No. PCT/FR2003/050072, entitled "Method for Making a Wire Nanostructure in a Semiconductor Film" by David FRABOULET, Jacques GAUTIER, Didier TONNEAU and Nicolas CLEMENT, which claims priority of French Application No. 02/12235, filed on October 3, 2002, and which was not published in English.